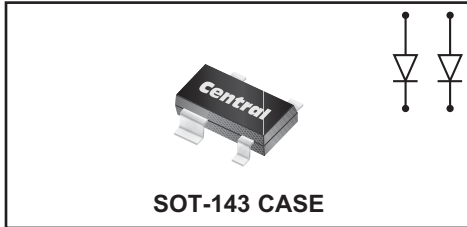


BAS56

**SURFACE MOUNT
DUAL, ISOLATED HIGH CURRENT
SILICON SWITCHING DIODES**



www.centrasemi.com

DESCRIPTION:

The CENTRAL SEMICONDUCTOR BAS56 consists of two electrically isolated ultra-high speed silicon switching diodes manufactured by the epitaxial planar process and packaged in an epoxy molded surface mount SOT-143 case. This device is designed for high speed switching applications.

MARKING CODE: L51 or WL5

MAXIMUM RATINGS: ($T_A=25^\circ\text{C}$)

Continuous Reverse Voltage
Peak Repetitive Reverse Voltage
Continuous Forward Current
Peak Repetitive Forward Current
Peak Forward Surge Current, $t_p=1.0\mu\text{s}$
Peak Forward Surge Current, $t_p=1.0\text{s}$
Power Dissipation
Operating and Storage Junction Temperature
Thermal Resistance

SYMBOL

V_R	60
V_{RRM}	60
I_F	200
I_{FRM}	400
I_{FSM}	4.0
I_{FSM}	1.0
P_D	350
T_J, T_{stg}	-65 to +150
θ_{JA}	357

UNITS

V
V
mA
mA
A
A
mW
$^\circ\text{C}$
$^\circ\text{C/W}$

ELECTRICAL CHARACTERISTICS PER DIODE: ($T_A=25^\circ\text{C}$ unless otherwise noted)

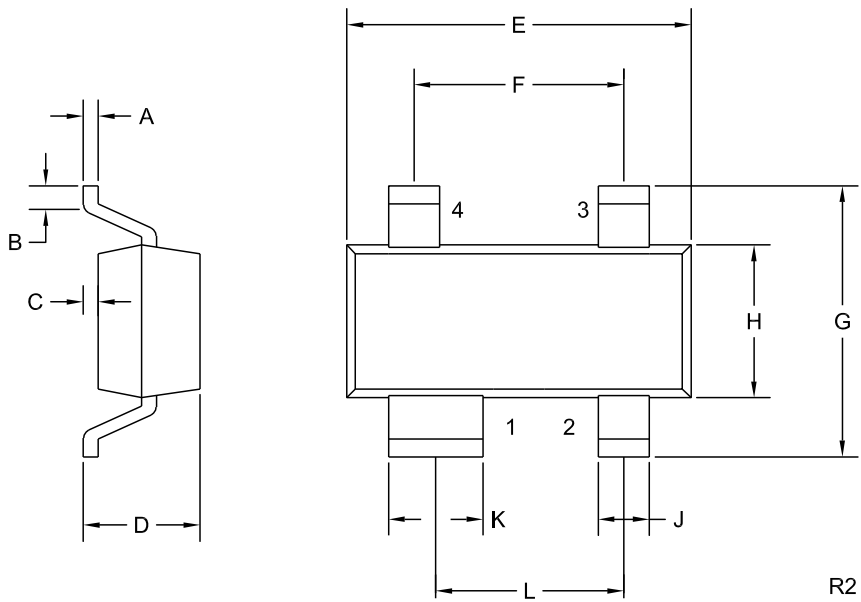
SYMBOL	TEST CONDITIONS	MIN	MAX	UNITS
I_R	$V_R=60\text{V}$		100	nA
I_R	$V_R=60\text{V}, T_A=150^\circ\text{C}$		100	μA
I_R	$V_R=75\text{V}$		10	μA
V_F	$I_F=10\text{mA}$		0.75	V
V_F	$I_F=200\text{mA}$		1.0	V
V_F	$I_F=500\text{mA}$		1.25	V
C_T	$V_R=0, f=1.0\text{MHz}$		2.5	pF
t_{rr}	$I_F=I_R=400\text{mA}, I_{rr}=40\text{mA}, R_L=100\Omega$		6.0	ns
Q_s	$I_F=10\text{mA}, V_R=5.0\text{V}, R_L=500\Omega$		50	pC
V_{FR}	$I_F=400\text{mA}, t_f=30\text{ns}$		1.2	V
V_{FR}	$I_F=400\text{mA}, t_f=100\text{ns}$		1.5	V

BAS56

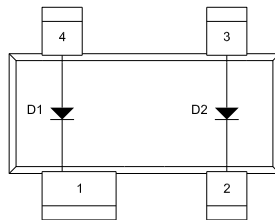
SURFACE MOUNT
DUAL, ISOLATED HIGH CURRENT
SILICON SWITCHING DIODES



SOT-143 CASE - MECHANICAL OUTLINE



PIN CONFIGURATION



LEAD CODE:

- 1) CATHODE D1
- 2) CATHODE D2
- 3) ANODE D2
- 4) ANODE D1

MARKING CODE: L51 or WL5

SYMBOL	DIMENSIONS	
	MIN	MAX
A	0.003	0.006
B	0.006	-
C	-	0.005
D	-	0.045
E	0.110	0.120
F	0.075	1.90
G	-	0.098
H	0.047	0.055
J	0.014	0.020
K	0.030	0.037
L	0.067	1.70

SOT-143 (REV: R2)

R7 (25-August 2010)